

# Junction Diode

## Lecture - 10

(10/06/2021)

**B.Sc (Electronics)**  
**TDC PART - I**  
**Paper – 1 (Group – B)**  
**Unit – 5**  
**by:**

**Dr. Niraj Kumar**

**Assistant Professor (Guest Faculty)**



**Department of Electronics**

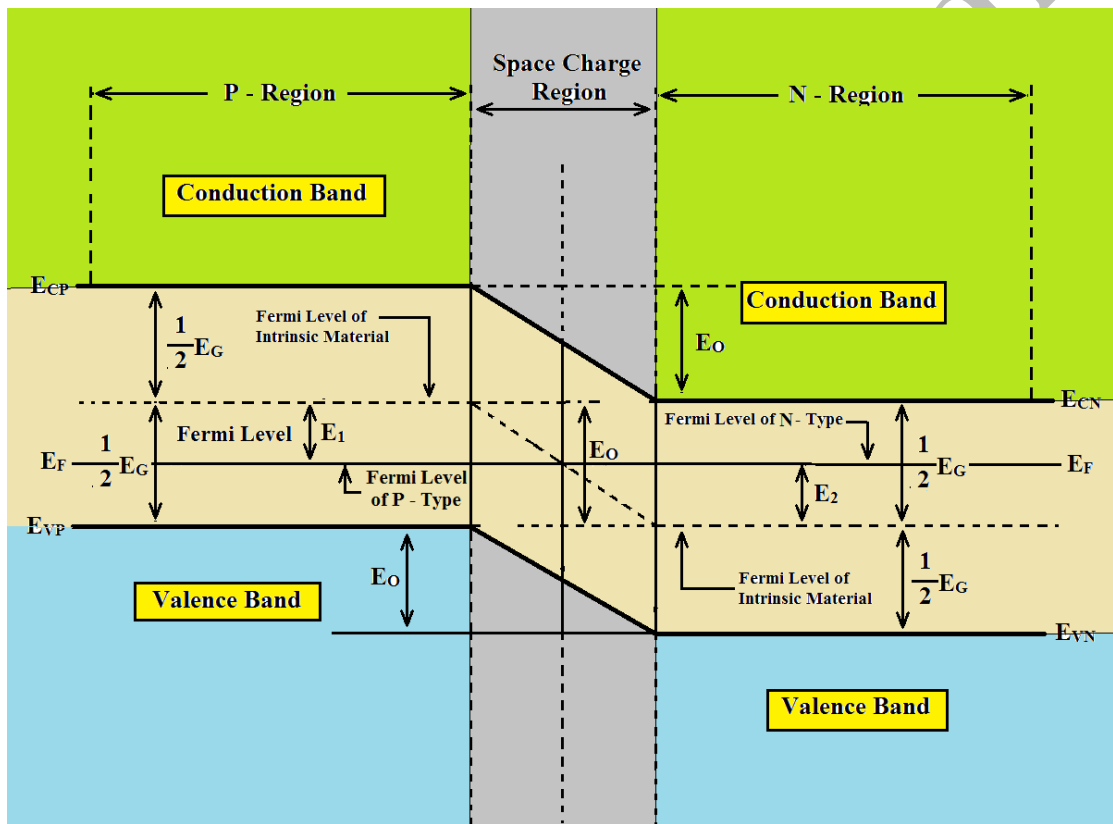
**L. S. College, BRA Bihar University, Muzaffarpur.**

---

### ➤ **Energy Band Structure of an Open-Circuited P-N Junction**

- ⇒ Let us consider that a P-N Junction is formed by placing P – type and N – type materials in intimate contact on an atomic scale. Under such conditions the Fermi-Level must be constant through-out the specimen at equilibrium.
- ⇒ **If this were not true**, Electrons on one side of the junction would have an average energy higher than those on the other side and there would be a transfer of electrons and energy until the Fermi Level on the two sides equalize. In **Previous Lecture – 40** and **Lecture – 41** we have already learn and see that **Fermi Level  $E_F$**  is closer to the **Conduction Band edge  $E_{CN}$**  in the N – type material and closer to the **Valence Band edge  $E_{VP}$**  in the P – type material.

⇒ Obviously the **Conduction Band edge  $E_{CP}$**  in the P - type material cannot be at the same level as  $E_{CN}$ , nor can the **Valence Band edge  $E_{VP}$**  in the N - side line up with  $E_{VN}$ . Thus on formation of a P-N Junction, **Conduction Band edge  $E_{CP}$**  in P - type material is higher than  $E_{CN}$  in N - type material and **Valence Band edge  $E_{VP}$**  in P - type material is higher than  $E_{VN}$  in N - type material. This is **illustrated below in Figure (1)**, where a **shift in energy level  $E_0$**  is shown.



**Fig. (1)** Shown Energy Band Structure of an Open-Circuit P-N Junction.

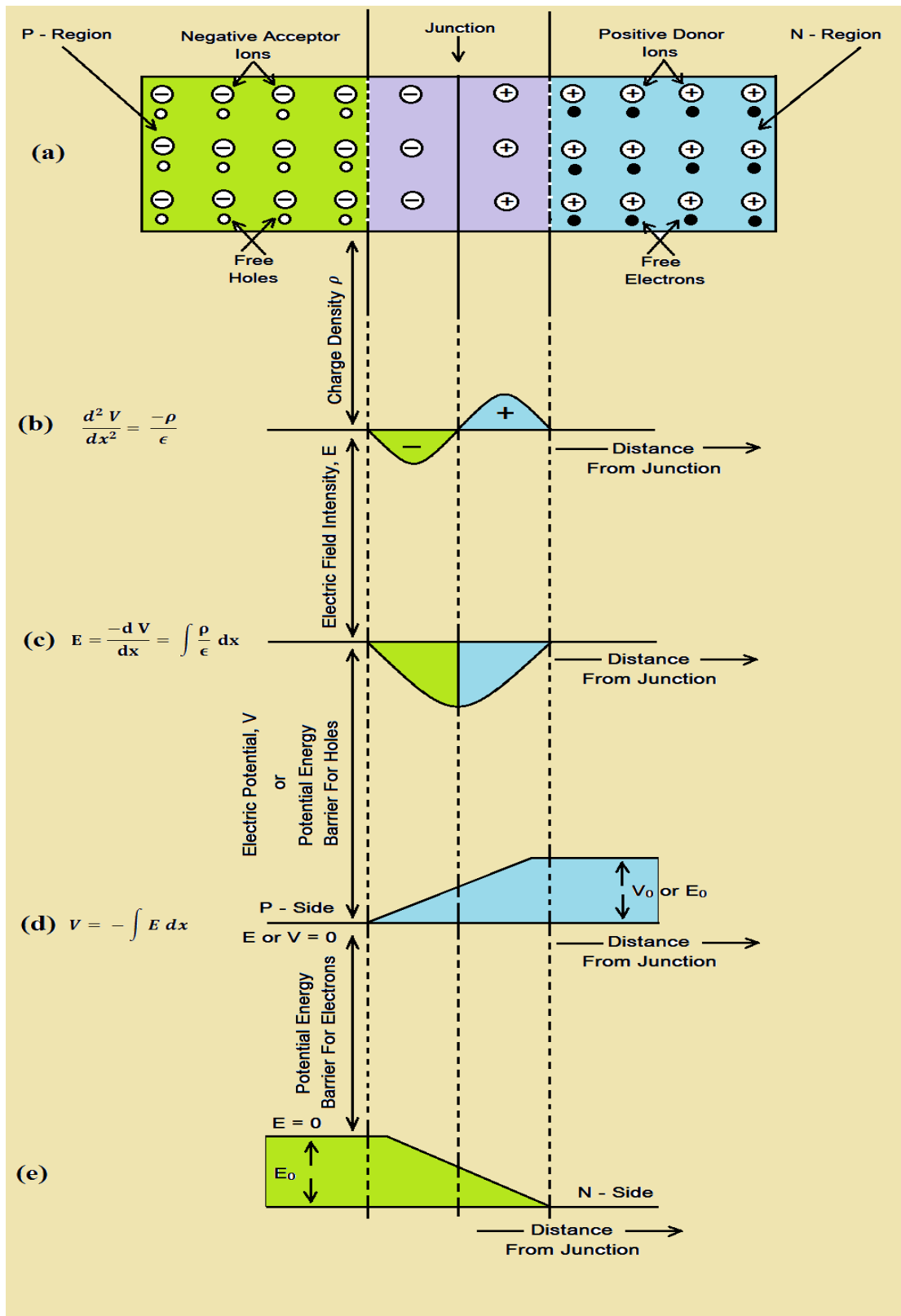
⇒ The Total shift in the **Energy Level  $E_0$**  is given as,

$$E_0 = E_{CP} - E_{CN} + E_{VP} - E_{VN} \quad \dots\dots\dots (62)$$

$$E_0 = E_1 + E_2 \quad \dots\dots\dots (63)$$

where,  $E_1$  and  $E_2$  represent the **shifts in the Fermi Level** from the Intrinsic Condition in P - type and N - type materials.

⇒ The Energy  $E_0$  represents the **Potential Energy of the Electrons at the Junction**, as shown below in **Figure (2) (e)**.



**Fig. (2)** Shown Energy  $E_0$  or  $V_0$  represents the **potential Energy of the Electrons at the Junction**.

⇒ Now, from **above Figure (1)**, we have,

$$E_F - E_{VP} = \frac{1}{2} E_G - E_1 \dots\dots\dots (64)$$

and

$$E_{CN} - E_F = \frac{1}{2} E_G - E_2 \dots\dots\dots (65)$$

⇒ Now **adding** above **Equation (64)** and **Equation (65)**, we have,

$$E_1 + E_2 = E_G - (E_{CN} - E_F) - (E_F - E_{VP}) \dots\dots\dots (66)$$

$E_o = E_G - (E_{CN} - E_F) - (E_F - E_{VP}) \dots\dots\dots (67)$
--

⇒ We already known from **Previous Lecture** that,

⇒ In **Intrinsic Semiconductor**, **Concentration of free Electrons n** in **Conduction Band** may be expressed as,

$$n = n_C e^{-(E_C - E_F)/kT} \dots\dots\dots (68)$$

and

⇒ In **Intrinsic Semiconductor**, **Concentration of free Holes p** in **Valence Band** may be expressed as,

$$p = n_V e^{-(E_F - E_V)/kT} \dots\dots\dots (69)$$

**where,**

- ★  $n_C$  is the number of Electrons in Conduction Band,
- ★  $n_V$  is the number of Electrons in the Valence Band,
- ★  $E_C$  is the lowest energy in the Conduction Band in eV,
- ★  $E_V$  is the maximum energy of Valence Band in eV.

⇒ Now, from **Law of Mass Action**, then we already have,

$$n p = n_i^2 \dots\dots\dots (70)$$

$$n_i^2 = n p$$

$$n_i^2 = n_C e^{-(E_C - E_F)/kT} \cdot n_V e^{-(E_F - E_V)/kT} \dots\dots\dots (71)$$

$$n_i^2 = n_C n_V e^{-(E_C - E_F)/kT} \cdot e^{-(E_F - E_V)/kT} \dots\dots\dots (72)$$

$$n_i^2 = n_C n_V e^{-[(E_C - E_F) + (E_F - E_V)]/kT} \dots\dots\dots (73)$$

$$n_i^2 = n_C n_V e^{-E_C - E_F + E_F - E_V /kT} \dots\dots\dots (74)$$

$$n_i^2 = n_C n_V e^{-(E_C - E_V)/kT} \dots\dots\dots (75)$$

$$n_i^2 = n_C n_V e^{-E_G/kT} \dots\dots\dots (76)$$

⇒ We already know from **Previous Lecture** that  $E_C - E_V = E_G$ , then we get,

$$\therefore n_i^2 = n_C n_V e^{-E_G/kT} \dots\dots\dots (77)$$

⇒ Again finally we can write the above **Equation (77)** as

$$\therefore E_G = kT \log_e \frac{n_C n_V}{n_i^2} \dots\dots\dots (78)$$

⇒ Now again, we already know from **Previous Lecture** that,

⇒ **Exact position of the Fermi Level** in an N – type of Extrinsic Semiconductor is give by,

$$E_F = E_C - kT \log_e \frac{n_C}{N_D} \dots\dots\dots (79)$$

$$E_{CN} - E_F = kT \log_e \frac{n_c}{N_D} \dots\dots\dots (80)$$

⇒ Again, **Exact position of the Fermi Level** in an P – type of Extrinsic Semiconductor is give by,

$$E_F = E_V - kT \log_e \frac{n_v}{N_A} \dots\dots\dots (81)$$

$$E_F - E_{VP} = kT \log_e \frac{n_v}{N_A} \dots\dots\dots (82)$$

⇒ Now substituting values of  $E_G$ ,  $(E_{CN} - E_F)$  and  $(E_F - E_{VP})$  from Equation (78), Equation (80) and Equation (82) in Equation (67), then we get,

$$E_o = E_G - (E_{CN} - E_F) - (E_F - E_{VP}) \dots\dots\dots (67)$$

$$E_o = kT \log_e \frac{n_c n_v}{n_i^2} - kT \log_e \frac{n_c}{N_D} - kT \log_e \frac{n_v}{N_A} \dots (83)$$

$$E_o = kT \log_e \left[ \frac{n_c n_v}{n_i^2} \cdot \frac{N_D}{n_c} \cdot \frac{N_A}{n_v} \right] \dots\dots\dots (84)$$

$$\therefore E_o = kT \log_e \frac{N_D N_A}{n_i^2} \dots\dots\dots (85)$$

⇒ **It is to be noted that** in above Equations all **E's** are expressed in **electron-volt** and **k** has the dimensions of **electron-volts per Kelvin**. The **contact difference of Potential** **V<sub>o</sub>** is expressed in **volts** and is **numerically equal** to **E<sub>o</sub>**.

⇒ It is obvious from above **Equation (84)** that  **$E_0$**  depends upon the **equilibrium concentrations** and not upon the **charge density** in transition region.

⇒ In the next **Lecture - 11**, we will discuss the detailed of the **Metal Semiconductor Junctions**.

**to be continued .....**

\*\*\*\*\*

Dr. Niraj Kumar